



PCT

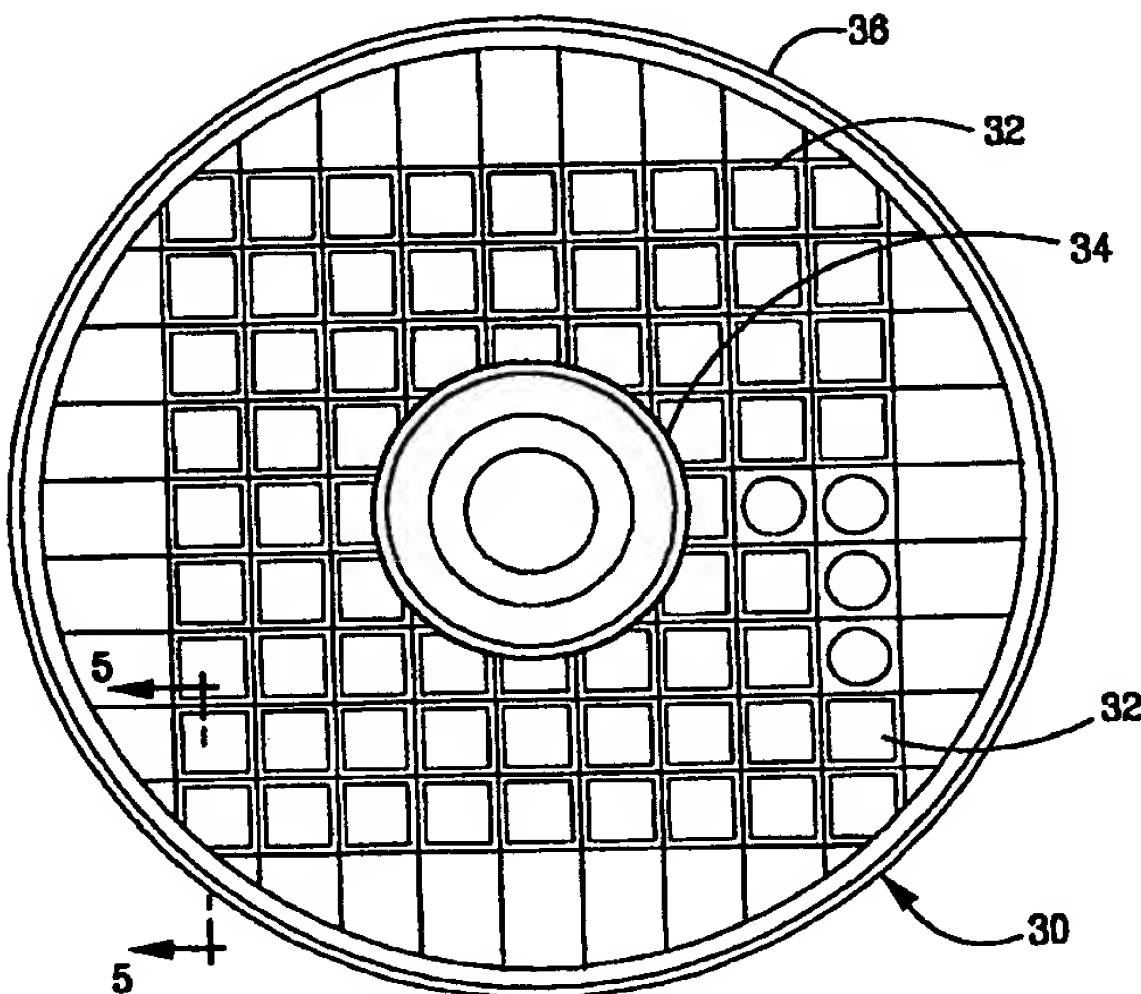
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(54) Title: **DIFFRACTIVE OPTICAL ELEMENTS**



(57) Abstract

A method for the replication of diffractive optical elements (32) using audio/video disc manufacturing equipment and processes. The audio/video disc manufacturing process and mold mastering tooling create diffractive optical elements (32) using a mold plate (14). The diffractive optic design and photomasks are first fabricated then replicated using compact disc industry mold mastering techniques. The surface relief pattern is produced centered in the plate using ion milling or refractive ion etching photolithographic fabrication techniques. Once patterned, the mold master plate (14) is punched into a circular form consistent with standard compact or video disc mold bases – typically eight inches for a compact disc. After molding, each element (32) can be cut out of the disc (30) using blade, shear, waterjet or laser cutting.

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## DIFFRACTIVE OPTICAL ELEMENTS

## BACKGROUND

The present invention relates to a method of manufacturing diffractive optical elements and more particularly to a method of manufacturing diffractive optical elements using photolithographic mastering and audio/video disc manufacturing equipment and processes.

Diffractive lens elements have been made by photolithographic manufacturing techniques. First, a pattern is produced by an optical designer with appropriate output file formats to be written by e-beam into a single or series of photomask(s). The patterns may have a distinct binary or multiphase grating designed to create a desired diffraction effect. Photolithographic processes are then used to transfer the pattern in the photomask(s) into a substrate having the necessary mechanical and transmissive characteristics. The substrate can be quartz, fused silica or other material.

It has also been suggested that diffractive lens elements or multiple diffractive and refractive integrated optical assemblies can be formed by plastic replication techniques. Photomasks are produced and used to create a master for molding. The mold materials must be durable

enough to withstand the molding process. The diffractive patterns are transferred to the mold master using photolithographic processes specifically characterized for the physical configuration and material being used.

5 U.S. Patent No. 5,538,674 to Nisper et al., the disclosure of which is incorporated herein by reference, illustrates a method of making holograms, kinoforms, diffractive optical elements and microstructures. U.S. Patent No. 5,013,494 to Kubo et al., the disclosure of which  
10 is incorporated herein by reference, illustrates a method of making desired surfaces using injection mold techniques.

Prior art systems for producing plastic diffractive lens elements or lens systems have a number of disadvantages. The molds are usually single purpose tools dictated by the  
15 physical size of the diffractive lens. Since each mold is designed for a specific application, a manufacturer may incur significant costs to justify tooling. In many cases, the projected volume of the product being produced will not justify the cost.

20 Thus, alternate manufacturing processes are used, such as straight etching of the desired pattern into a substrate which is then cut to the desired form factors. In order to maintain the maximum efficiency of the diffractive lens,

multiple phase steps are required by the design. In manufacturing, this requires the initial etching of the pattern using photolithographic processes and subsequent mask alignment or multiple mask alignment to the previous etch or etches. This process is both time consuming and costly.

Moreover, even in cases where the production volume justifies the expense to produce a mold base, there is the disadvantage that the system can produce only one optical element or lens system per molding operation. An additional disadvantage is the production lead time required. The production lead time may exceed six months for the design and construction of the mold.

Moreover, custom tooling and refined characterization of the photolithographic procedures may be required. In addition, significant time may be required to characterize both the new mold and the molding process for the specific application. Even during production, the throughput or capacity of the mold is often limited.

In cases where a mold is "reused" for multiple products, the generic mold base must be fitted with diffractive pins customized for the application. These pins must be fabricated and then etched with the desired patterns. This may require weeks of tooling to complete.

## SUMMARY OF THE INVENTION

The present invention alleviates to a great extent the disadvantages of the prior art by using existing audio/video disc manufacturing processes and equipment to create  
5 diffractive optical elements.

In one aspect of the invention, audio/video manufacturing equipment is modified and used to manufacture an array of diffractive optical elements.

It is an object of the present invention to reduce the  
10 time required to realize end products from design inputs. With the present invention, once photomasks are produced for the designed optic, mold mastering may be accomplished in a few days. Once a plate with the desired surface relief pattern is completed, plastic products can be produced in a  
15 few hours. Thus, the time it takes to produce a new product is reduced.

It is another object of the present invention to utilize the existing capital equipment base residing in the compact disc industry. U.S. Patent No. 4,185,955 to Holmes  
20 et al. and U.S. Patent No. 4,707,321 to Segawa, the disclosures of which are incorporated herein by reference, illustrate systems for molding centrally apertured video disc records. The molds used by the invention reside in large

numbers in industry. As new technology emerges for mass storage of digital data, these molds will become even more accessible to the optics industry. Diffractive optics being produced by these techniques have recurring costs an order of magnitude less than those being produced using other technology.

It is another object of the present invention to use pre-existing photolithographic masks to produce molds used with audio/video compact disc manufacturing equipment.

It is another object of the present invention to produce high quality optical products. Manufacturing process used by the compact disc industry are well documented and defined by compact disc manufacturers. Molding characteristics of polycarbonate for compact discs is also well understood by those in the compact disc industry. Thus, compact disc manufacturing equipment can be used in the present invention to produce high quality optical elements.

It is another object of the present invention to create diffractive optics in an essentially planar array.

This allows large elements to be stacked together to correct optical aberrations much in the same way as conventional glass lenses may be aligned to correct for chromatic and spherical aberrations.

Creating diffractive optics in an essentially circular planar array also allows stacked elements to be rotated with respect to each other about their central axis. This allows variability in polarization, beam scanning, and wavelength selection to be accomplished.

It is another object of the present invention to provide industry with a low cost, high production volume process for the replication of diffractive optics.

Other objects and advantages of the invention will be readily apparent from the following description and drawings which illustrate preferred embodiments of the invention.

#### BRIEF DESCRIPTION OF THE DRAWINGS

FIGS. 1a through 1c show the steps used to manufacture optical elements according to a preferred embodiment of the invention.

FIGS. 2a and 2b show the steps used to manufacture optical elements according to another preferred embodiment of the invention.

FIG. 3 is a plan view of a nickel master plate for creating diffractive optical elements.

FIG. 4 is a plan view of a polycarbonate disc formed using the nickel master plate of FIG. 3.



FIG. 5 is a partial cross sectional view of the disc shown in FIG. 4.

FIG. 6 is an enlarged plan view of a diffractive lenslet cut from the polycarbonate disc shown in FIG. 4.

5        FIG. 7 is an enlarged plan view of a diffractive grating cut from the polycarbonate disc shown in FIG. 4.

#### DETAILED DESCRIPTION OF PREFERRED EMBODIMENTS

Referring now to the drawings, where like numerals  
10       designate like elements, there is shown in FIGS. 1a through  
1c the steps used to manufacture optical elements according  
to a preferred embodiment of the invention. Optical patterns  
are etched into a substrate 10 to form an etched substrate 12  
(FIG. 1b). For clarity of illustration, the pattern itself  
15       is not shown in the FIGS. 1a through 1c. The etched  
substrate 12 is used to create a mold master 14 with  
corresponding negative patterns. Then, the mold master 14 is  
used in a mold 16 to create a disc 18 with optical patterns  
corresponding to those that were etched into the substrate 10  
20       (12).

The diffractive optic pattern can be etched into the  
substrate 10 using photomasks (not shown) and lithographic  
techniques. The substrate 10 may be quartz, fused silica or

other suitable material. Once the patterns have been developed, the mold master is electro-deposited on the etched substrate. The plate 14 is typically formed of nickel-plated material, but any alloy suitable for the mold base and process can also be used. The diameter of the mold plate 14 may be from about four to about fourteen inches for compact and laser disc molding. The mold plate 14 may have a thickness from about two hundred and seventy to about four hundred microns. The actual thickness of the plate 14 can be varied depending on the desired mechanical stability, surface RMS, and flatness desired or required by the diffractive design.

The mold plate 14 is shown in more detail in FIG. 3. The overall diameter of the master mold plate 14 is approximately seven and one half inches. Only the patterns 22 in the central region four and one half inches in diameter are used to create optical elements. These optical patterns 22 are represented by the smaller squares between the ruled lines 24.

The working diameter of the diffractive patterns 22 cannot exceed about four and three quarter inches circular for the standard compact disc mold bases, or eleven and eight tenths inches diameter for the standard video disc mold base.

Individual diffractive patterns 22, therefore, can range in size up to the maximum working diameter of the mold base 14. However, any patterns 22 in the central one and a half inch diameter of the plate 14 will not produce optical elements because this area is used by the mold base 14 as the injection sprue for the plastic resin out of which the diffractive parts 22 will be made.

The large area available for molding allows multiple diffractive patterns 22 to be formed onto the mold plate 14. With a one millimeter (mm) allowance between patterns 22 for cutting, for instance, five hundred and twelve diffractive patterns on three mm centers, or one hundred and fifty five diffractive patterns on five mm centers can be formed on one mold plate 14. It is also possible to form a lesser number of larger diameter diffractive parts.

The mold master plate 14, once patterned, is then punched into a circular form consistent with standard compact or video disc mold bases - typically eight inches for a compact disc. During the punching process, the center of the plate (shown in dotted lines in FIG. 3 and designated by reference numeral 26) is removed to form a circular hole and the mold master plate is placed in the mold base.

Production of the diffractive lenses results from manufacturing process consistent with compact disc and video disc production. Typical materials used in this replication process are optical grade polycarbonate, acrylic or other  
5 suitable polymers.

FIGS. 4 and 5 show an annular disc 30 or plate in which many different diffractive elements 32 have been produced in polycarbonate using the mold plate 14 shown in FIG. 3. The disc 30 has a circular hole in the center 34 and  
10 a circular periphery 36. The disc 30 may have a thickness of one and three tenths millimeters (mm). The disc 30 can also be to be only half as thick as a standard compact disc, or .65 mm. Recently developed processes related to high density compact discs, or digital video discs (DVD) enable  
15 replication of diffractive lens elements with thicknesses of .625 mm.

After molding, each element 32 may be cut out of the disc 30 using blade, shear, waterjet or laser cutting.

FIGS. 6 and 7 show examples of individual diffractive  
20 elements 32 cut from the disc 30 shown in FIGS. 4 and 5.

A second method for creating mold masters with diffractive patterns is to etch the positive diffractive surface relief pattern, using photolithographic techniques,

directly into a nickel substrate electroformed on a mirror block. FIGS. 2a and 2b show the steps used to manufacture optical elements according to this preferred embodiment of the invention. As shown in FIG. 2a, an optical pattern is etched into a mold master 14. This mold master 14 is then placed in a mold 16' and an optical element 18 is created as shown in FIG. 2b.

Although preferred embodiments are specifically illustrated and described herein, it will be appreciated that modifications and variations of the present invention are covered by the above teachings and within the purview of the appended claims without departing from the spirit and intended scope of the invention. For example, the processes defined herein can be used to replicate both refractive and reflective diffractive optical elements. Surface patterns for spherical and aspheric lenses, diffractive and refractive micro-lens arrays can all be replicated in plastic and other materials using the techniques described. Large diffractive optics of diameters up to fourteen inches can also be mass produced using this process.

What is claimed as new and desired to be secured by Letters Patent of the United States is:

1. A method of manufacturing an optical element, said method comprising the steps of:

forming a pattern on a first element;

5 using said first element to produce a mold master element having a negative pattern corresponding to the pattern on said first element; and

using said mold master element to form a plurality of annular plates, with each of said plates having a molded optical element.

10

2. A method of manufacturing an optical element according to claim 1, wherein said step of using said mold master element to form said plurality of annular plates is performed using audio/video disc manufacturing equipment.

15

3. A method of manufacturing an optical element according to claim 1, wherein said optical element is a diffractive optical element.

20

4. A method of manufacturing an optical element according to claim 1, wherein said optical element is a refractive optical element.

5. A method of manufacturing an optical element according to claim 1, wherein said optical element is a refractive and diffractive optical element.

5           6. A method of manufacturing an optical element according to claim 1, wherein said annular plates each have a circular hole in the center.

10           7. A method of manufacturing an optical element according to claim 6, wherein said annular plates each have a circular periphery.

15           8. A method of manufacturing an optical element according to claim 1, wherein said first element is formed of quartz.

          9. A method of manufacturing an optical element according to claim 8, wherein said mold master element is formed of a nickel plated material.

20           10. A method of manufacturing an optical element according to claim 1, wherein said pattern formed on said

first element is formed by an ion milling photolithographic fabrication technique.

11. A method of manufacturing an optical element  
5 according to claim 1, wherein said pattern formed on said first element is formed by a reactive ion etching fabrication technique.

12. A method of manufacturing an optical element  
10 according to claim 11, wherein said mold master element is electro-formed using said first element.

13. A method of manufacturing an optical element  
15 according to claim 1, wherein said mold master element has a diameter of about seven and one half inches.

14. A method of manufacturing an optical element  
according to claim 1, wherein said plurality of annular plates are optical grade polycarbonate.

20 15. A method of manufacturing an optical element according to claim 1, wherein said plurality of annular plates are acrylic.



16. A method of manufacturing a plurality of optical elements, said method comprising the steps of:

forming a plurality of patterns on a first element;

5 using said first element to produce a mold master element having a plurality of negative patterns corresponding to the patterns on said first element; and

10 using said mold master element to form a plurality of annular plates, with each of said plates having a plurality of molded optical elements.

17. A method of manufacturing a plurality of optical elements according to claim 16, wherein said step of using said mold master element to form said plurality of annular plates is performed using audio/video disc manufacturing equipment.

18. A method of manufacturing a plurality of optical elements according to claim 17, wherein said plurality of optical elements are diffractive optical elements.

19. A method of manufacturing a plurality of optical elements according to claim 18, wherein said annular plates each have a circular hole in the center.

5           20. A method of manufacturing a plurality of optical elements according to claim 19, wherein said annular plates each have a circular periphery.

10           21. A method of manufacturing a plurality of optical elements according to claim 16, wherein said first element is formed of quartz.

15           22. A method of manufacturing a plurality of optical elements according to claim 21, wherein said mold master element is formed of nickel plated material.

20           23. A method of manufacturing a plurality of optical elements according to claim 16, further comprising the step of separating said plurality of optical elements.

24. An annular plate formed by the method of claim 16.

25. A method of manufacturing an optical element,  
said method comprising the steps of:

forming a pattern on a mold master element; and

5 using said mold master element to form a plurality of  
annular plates, with each of said plates having a molded  
optical element.

26. A method of manufacturing an optical element  
according to claim 25, wherein said step of using said mold  
10 master element to form said plurality of annular plates is  
performed using audio/video disc manufacturing equipment.

27. A method of manufacturing an optical element  
according to claim 26, wherein said optical element is a  
15 diffractive optical element.

## AMENDED CLAIMS

[received by the International Bureau on 26 June 1998 (26.06.98);  
original claims 1,2,8-13,25 and 26 cancelled; original claims  
3-7,14,15,19 and 27 amended; new claims 28-35 added; remaining  
claims unchanged (7 pages)]

3. A method of manufacturing an optical element  
according to claim 35, wherein said optical element is a  
diffractive optical element.

5 4. A method of manufacturing an optical element  
according to claim 35, wherein said optical element is a  
refractive optical element.

10 5. A method of manufacturing an optical element  
according to claim 35, wherein said optical element is a  
refractive and diffractive optical element.

15 6. A method of manufacturing an optical element  
according to claim 35, wherein said annular plate has a  
circular hole in the center.

20 7. A method of manufacturing an optical element  
according to claim 6, wherein said annular plate has a  
circular periphery.

14. A method of manufacturing an optical element according to claim 35, wherein said plate is optical grade polycarbonate.

5

15. A method of manufacturing an optical element according to claim 35, wherein said annular plate is acrylic.

16. A method of manufacturing a plurality of optical elements, said method comprising the steps of:

10

forming a plurality of patterns on a first element;

using said first element to produce a mold master element having a plurality of negative patterns corresponding to the patterns on said first element; and

15

using said mold master element to form a plurality of annular plates, with each of said plates having a plurality of molded optical elements.

20

17. A method of manufacturing a plurality of optical elements according to claim 16, wherein said step of using

said mold master element to form said plurality of annular plates is performed using audio/video disc manufacturing equipment.

5           18. A method of manufacturing a plurality of optical elements according to claim 17, wherein said plurality of optical elements are diffractive optical elements.

10           19. A method of manufacturing a plurality of optical elements according to claim 18, further comprising the step of forming a circular hole in the center of each annular plate.

15           20. A method of manufacturing a plurality of optical elements according to claim 19, wherein said annular plates each have a circular periphery.

20           21. A method of manufacturing a plurality of optical elements according to claim 16, wherein said first element is formed of quartz.

22. A method of manufacturing a plurality of optical elements according to claim 21, wherein said mold master element is formed of nickel plated material.

5

23. A method of manufacturing a plurality of optical elements according to claim 16, further comprising the step of separating said plurality of optical elements.

10

24. An annular plate formed by the method of claim 16.

15

27. A method of manufacturing an optical element according to claim 35, wherein said optical element is a diffractive optical element.

20

28. The method of claim 16, wherein individual patterns are separated from other patterns by spaces, and wherein said method further comprises the step of cutting

through said spaces to separate said optical elements from each other.

29. The method of claim 17, wherein the annular  
5 plates contain no memory information.

30. A method of manufacturing a mold master for forming an optical element having an optical pattern, the method comprising the steps of:

10       applying photoresist to a surface;  
          exposing the photoresist to form a pattern;  
          developing the photoresist to form a mask in the shape of the pattern; and  
          dry-etching a surface relief structure corresponding  
15 to the mask into the surface.

31. The method of claim 30, wherein the surface is part of a substrate, and the dry-etched areas form a duplicate of the optical pattern, further comprising the  
20 steps of:



depositing a metallic layer on the surface such that a negative of the optical pattern on the substrate is formed in the metallic layer; and

5 separating the metallic layer from the smooth surface such that the metallic layer forms the mold master.

32. The method of claim 31, wherein the dry-etching step is performed by reactive ion etching.

10 33. The method of claim 31, wherein the dry-etching step is performed by ion milling.

34. The method of claim 31, wherein the depositing step is performed by electro-depositing the metallic layer.

15

35. A method of manufacturing an optical element, the method comprising the steps of:

creating a mold master having a negative of at least one optical pattern;

20

using the mold master with audio/video disc  
manufacturing equipment to form an annular plate with the  
optical pattern and without any memory information.

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FIG. 1A

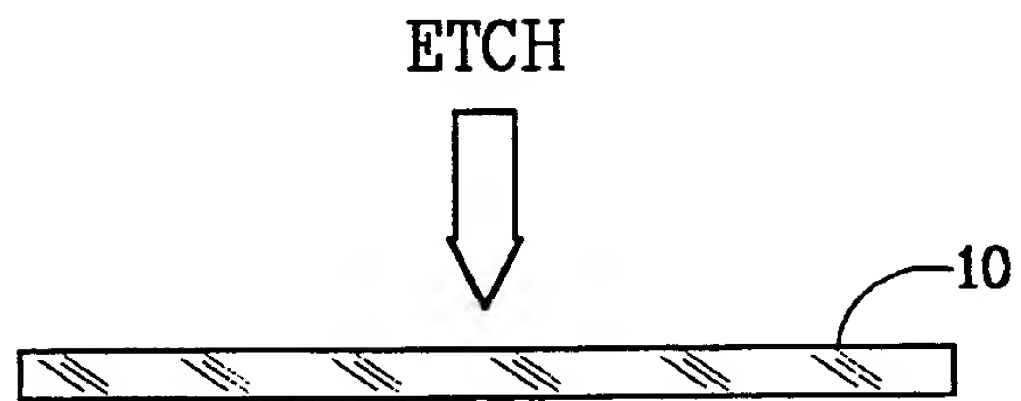


FIG. 1B

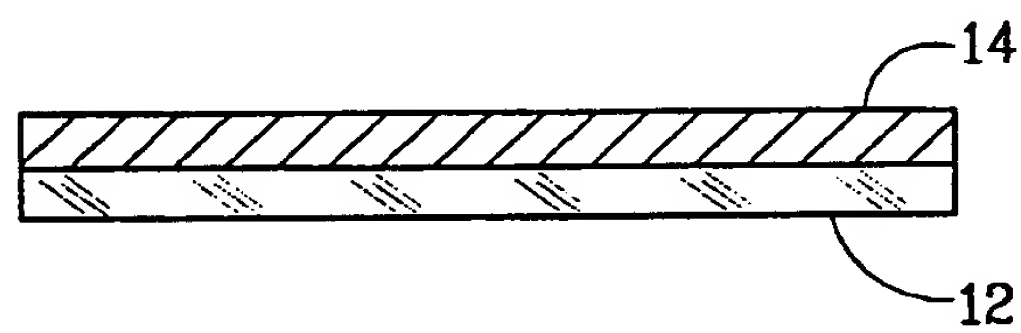


FIG. 1C

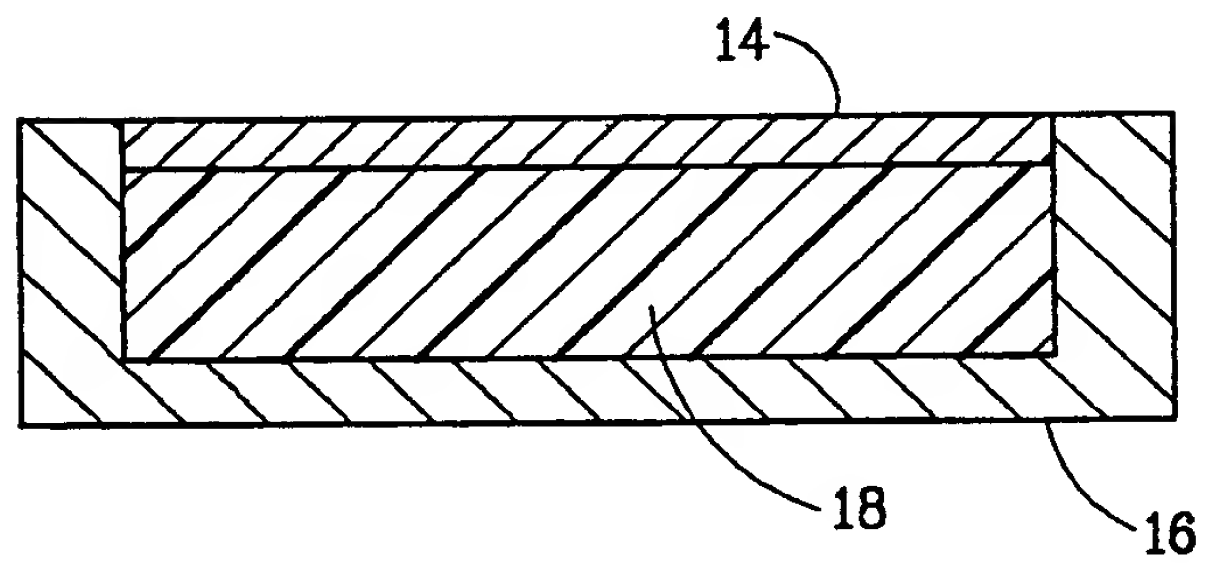


FIG. 2A

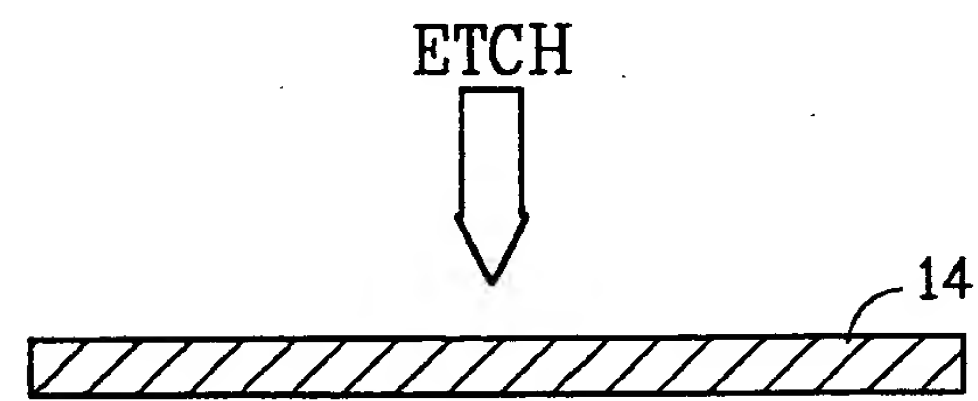
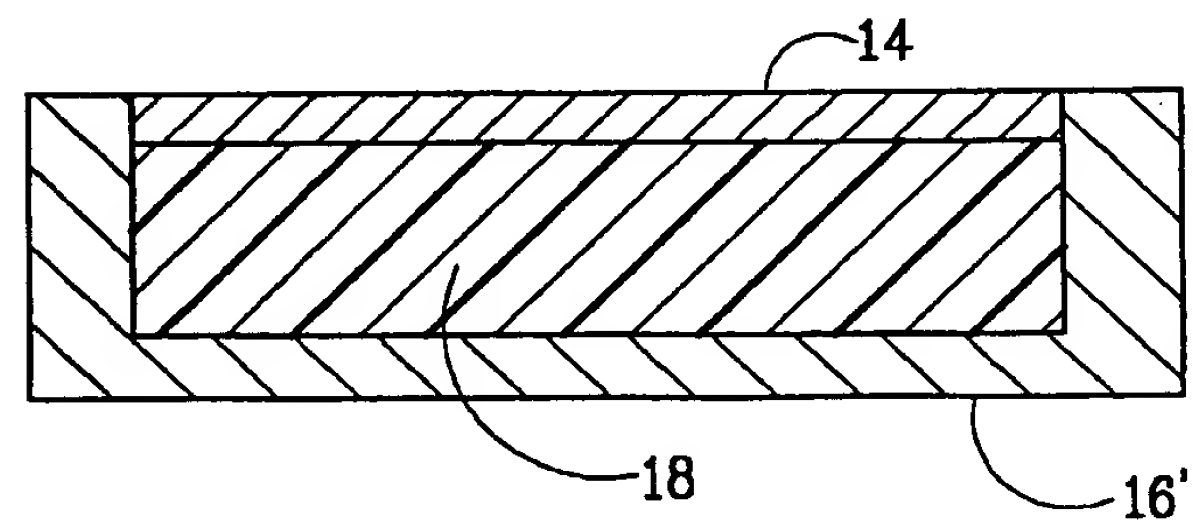


FIG. 2B



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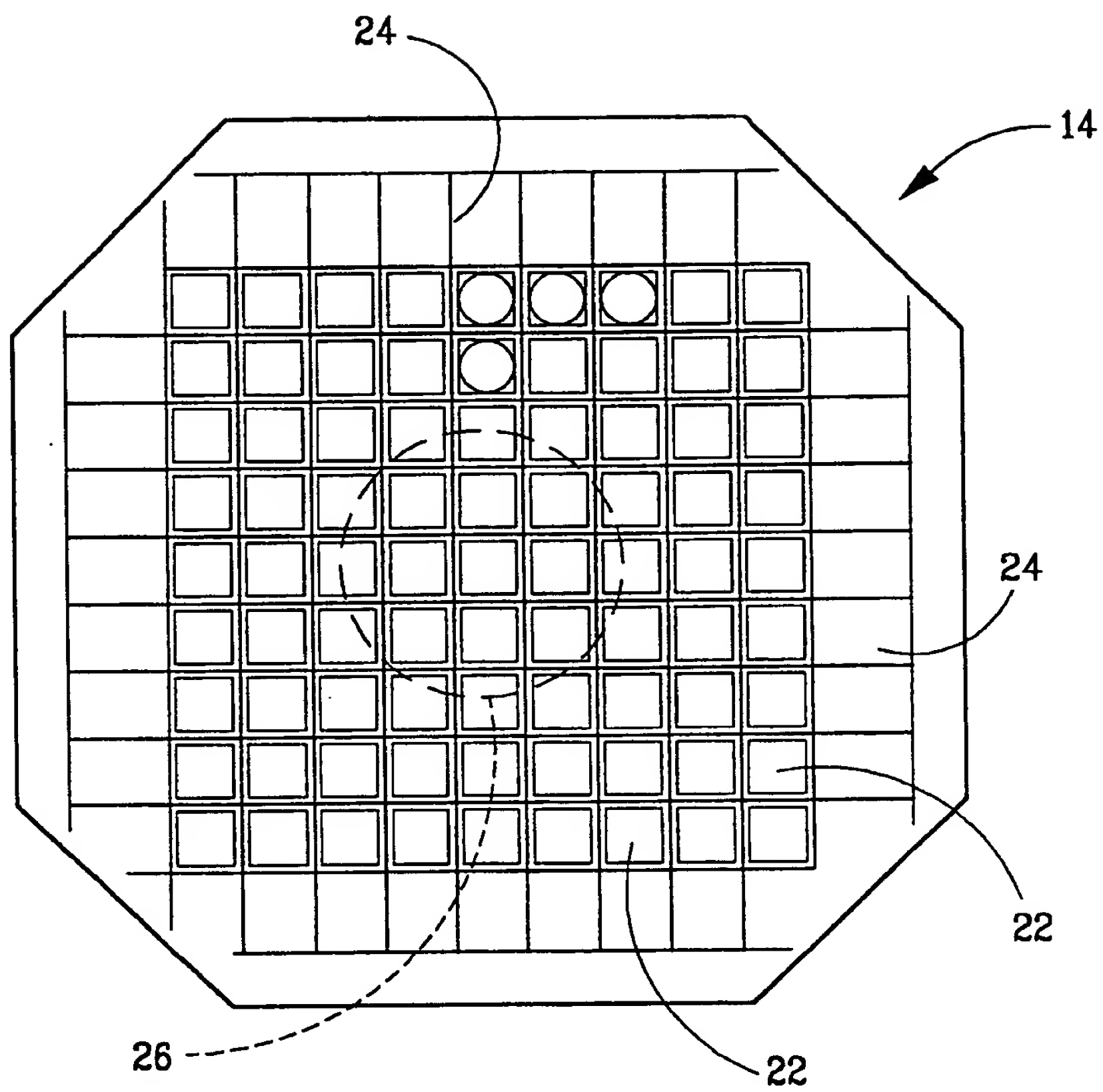


FIG. 3

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FIG. 4

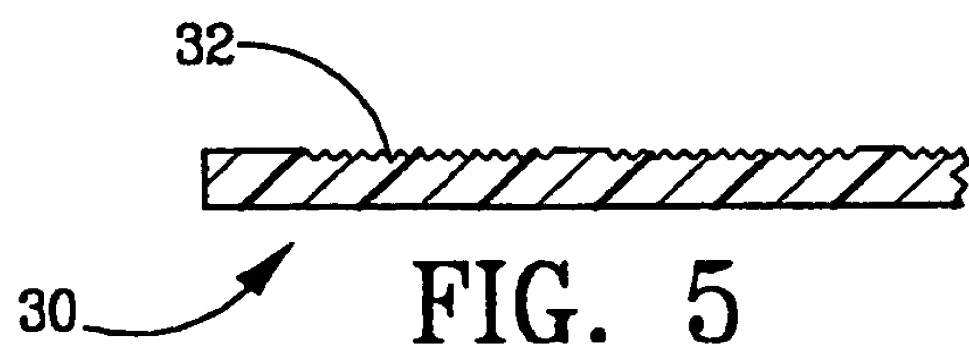
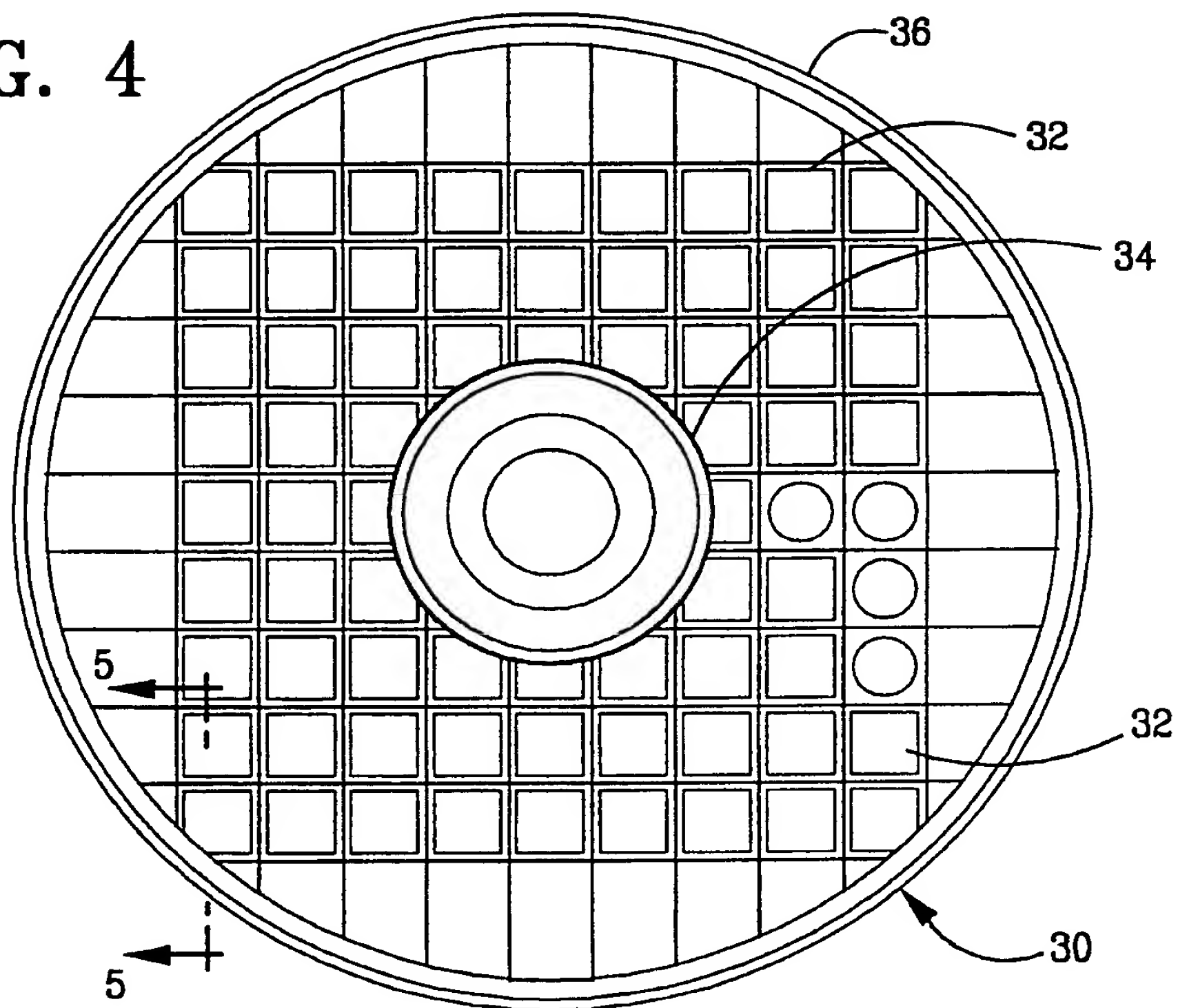


FIG. 5

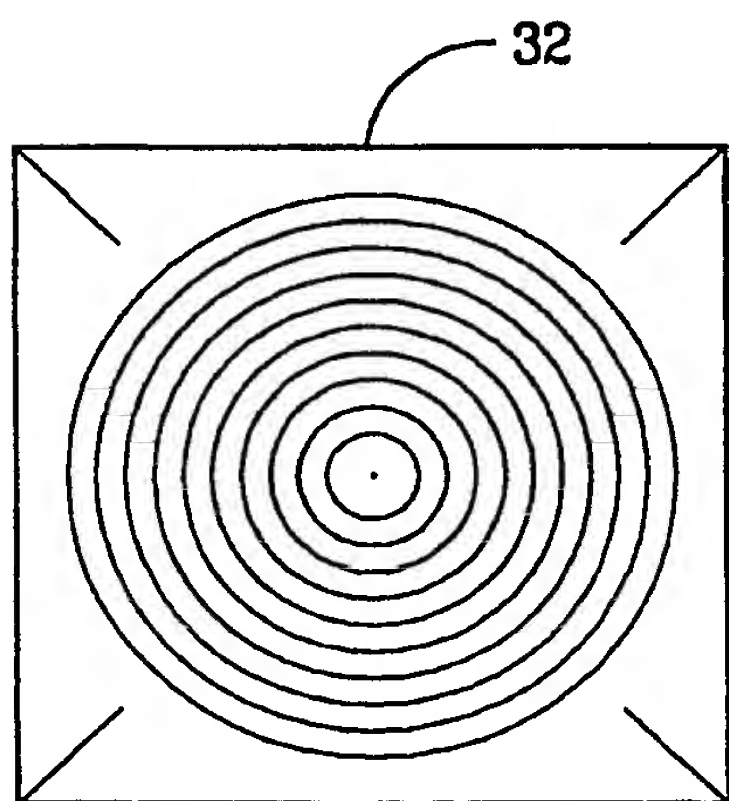


FIG. 6

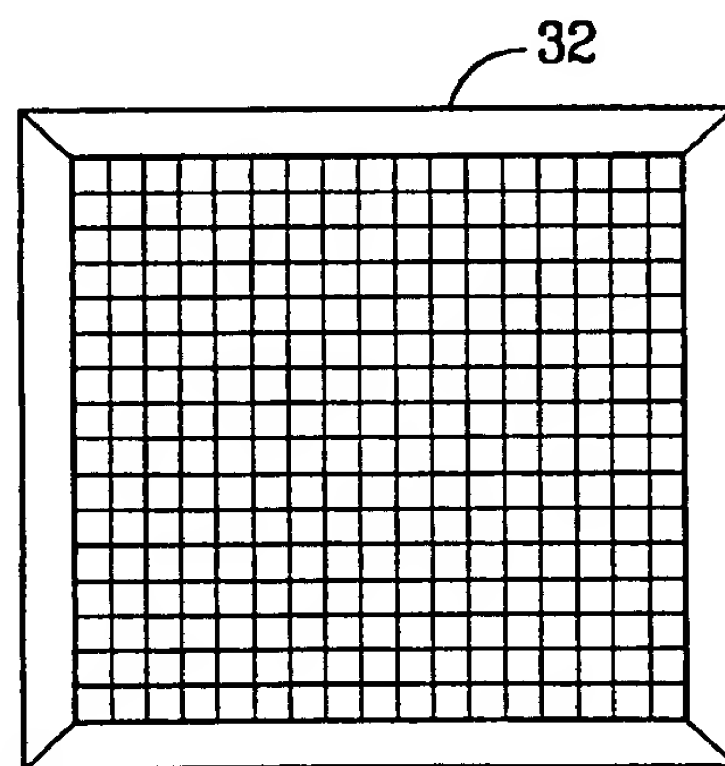


FIG. 7

## INTERNATIONAL SEARCH REPORT

International application No.  
PCT/US98/01342

## A. CLASSIFICATION OF SUBJECT MATTER

IPC(6) :B29D 11/00, 17/00

US CL :264/1.33, 1.36, 2.5; 369/275

According to International Patent Classification (IPC) or to both national classification and IPC

## B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

U.S. : 264/1.33, 1.36, 2.5, 485, 162; 369/275; 425/810

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

## C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X — Y	US 5,189,531 A (PALMER et al) 23 February 1993, col. 4, line 54 through col. 5, line 11	25-27 ----- 1-24
Y	US 5,538,674 A (NISPER et al) 23 July 1996, see whole document	1-24

☐ Further documents are listed in the continuation of Box C. ☐ See patent family annex.

* Special categories of cited documents:	*T* later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention
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Date of the actual completion of the international search

09 APRIL 1998

Date of mailing of the international search report

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